| L Number | Hits | Search Text | DB | Time stamp |
|---|---|---|---|---|
| 8 | 1 | photo near4 (cure cured curing curable) and "20020031874" .pn. | USPAT; US-PGPUB | 2004/09/01 18:51 |
| 18 | 125 | (ultraviolet UV) WITH visible with electron adj beam with (cure cured curing curable) with (polymer resin epoxy) | USPAT; US-PGPUB; JPO; DERWENT; IBM_TDB | 2004/09/01 19:07 |
| 19 | 19 | ((ultraviolet UV) WITH visible with electron adj beam with (cure cured curing curable) with (polymer resin epoxy)) and silane adj coupling | USPAT; US-PGPUB; JPO; DERWENT; IBM_TDB | 2004/09/01 19:08 |
| 23 | 837 | (ULTRAVIOLET UV) ADJ ABSORBER AND (hindered adj amine) AND (PERCENTAGE PERCENT) | USPAT; US-PGPUB | 2004/09/01 19:13 |
| 40 | 3 | (US-6114090-$ or US-4317862-$).did. or (US-20020031874-$).did. | USPAT; US-PGPUB | 2004/09/01 19:28 |
| - | 46 | encapsulant WITH photoresist | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/09/01 13:51 |
| - | 2387 | lens WITH photoresist | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/09/01 13:51 |
| - | 56 | (light adj emitting adj diode) and (lens WITH photoresist) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/09/01 13:52 |
| - | 95907 | light adj emitting adj diode | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/09/01 14:37 |
| - | 118927 | silane | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/09/01 14:37 |
| - | 26500 | silane adj coupling | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/09/01 14:39 |
| - | 107 | ((silane adj coupling ) and @pd<19900101) and (photoresist photo adj resist photo-resist) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/09/01 15:35 |
| - | 10418 | hindered adj amine | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/09/01 15:04 |
| - | 111 | (hindered adj amine) and (photoresist photo adj resist photo-resist) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/09/01 15:06 |
| - | 1 | ("4563438").PN. | USPAT; US-PGPUB | 2004/09/01 15:33 |

| - | 12 | ((ULTRAVIOLET UV) ADJ ABSORBER AND (hindered adj amine) AND (PERCENTAGE PERCENT)) and (photoresist photo adj resist photo-resist) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/09/01 16:22 |
|---|---|---|---|---|
| - | 75 | clear adj (photoresist photo adj resist photo-resist) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/09/01 16:50 |
| - | 156 | transparent adj (photoresist photo adj resist photo-resist) not (clear adj (photoresist photo adj resist photo-resist)) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/09/01 17:26 |
| - | 1935 | ((257/99,100) or (438/22)).CCLS. | USPAT; US-PGPUB | 2004/09/01 17:26 |
| - | 4455 | photo near4 (cure cured curing curable) | USPAT; US-PGPUB | 2004/09/01 18:51 |
| - | 13 | (((257/99,100) or (438/22)).CCLS.) and (photo near4 (cure cured curing curable)) | USPAT; US-PGPUB | 2004/09/01 17:51 |
| - | 4 | "6018167" | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/09/01 17:29 |
| - | 1 | "20020031874" and (photo near4 (cure cured curing curable)) | USPAT; US-PGPUB | 2004/09/01 17:53 |
| - | 2 | (((257/99,100) or (438/22)).CCLS.) and photosetting not ((((257/99,100) or (438/22)).CCLS.) and (photo near4 (cure cured curing curable))) | USPAT; US-PGPUB | 2004/09/01 17:54 |